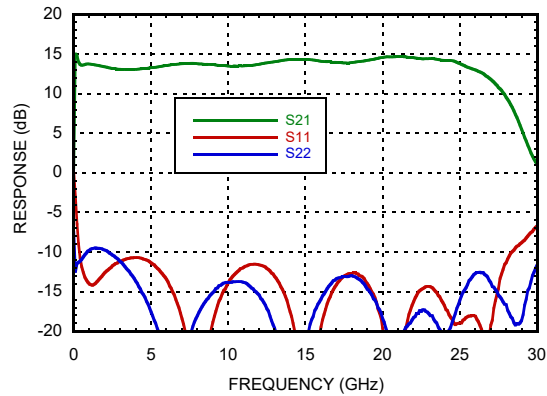
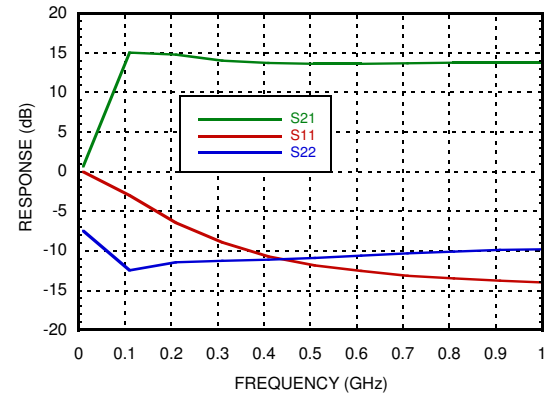


**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

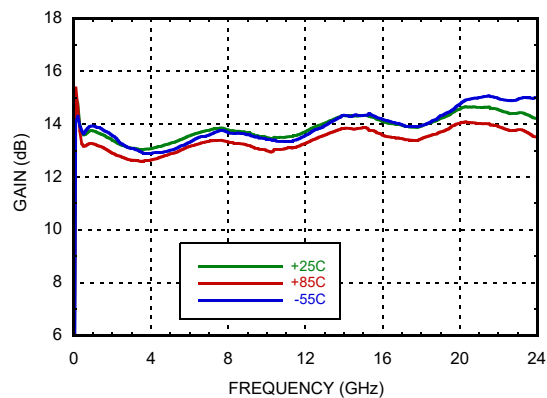
Gain & Return Loss



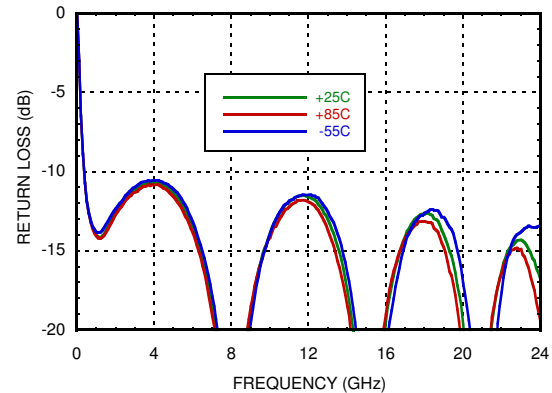
Low Frequency Gain & Return Loss



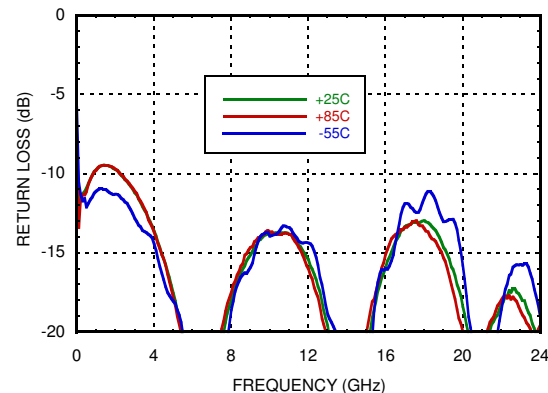
Gain vs. Temperature



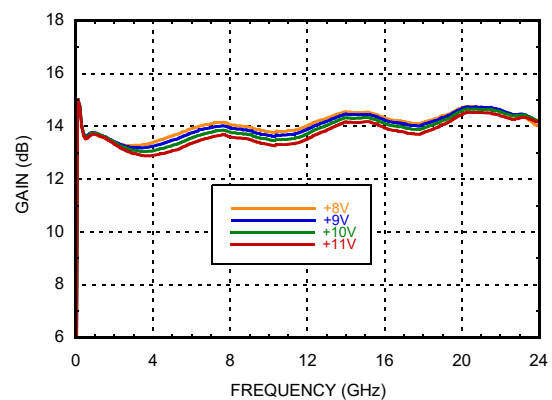
Input Return Loss vs. Temperature



Output Return Loss vs. Temperature

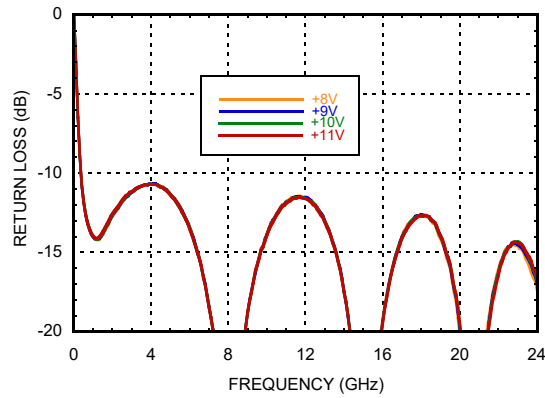


Gain vs. Supply Voltage

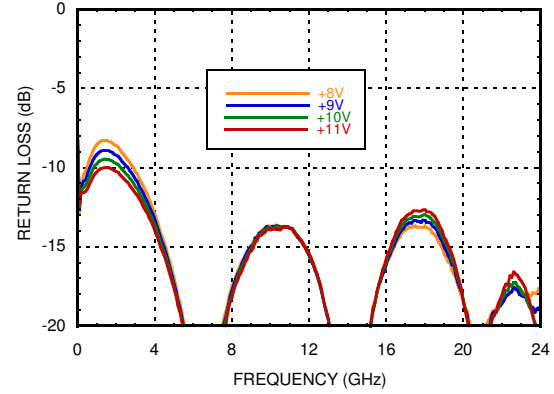


**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

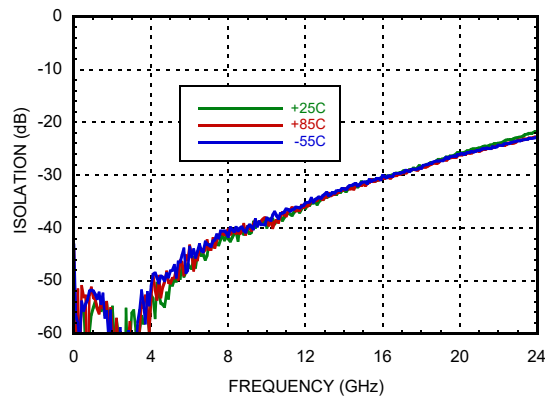
Input Return Loss vs. Supply Voltage



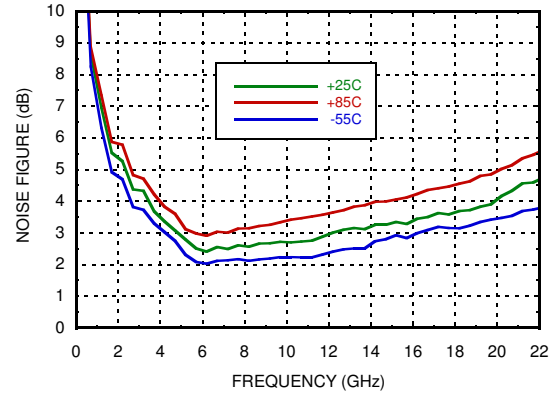
Output Return Loss vs. Supply Voltage



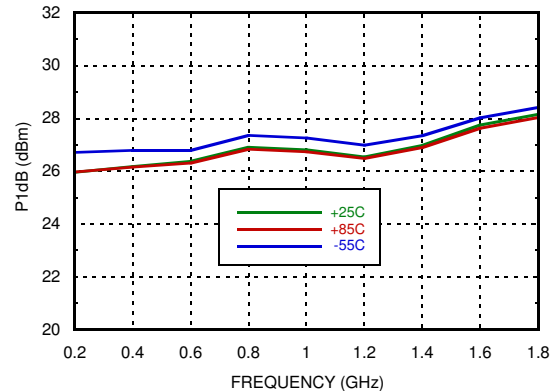
Reverse Isolation vs. Temperature



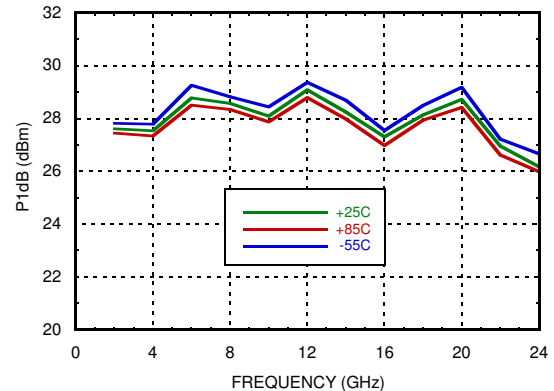
Noise Figure vs. Temperature



Low Frequency P1dB vs. Temperature

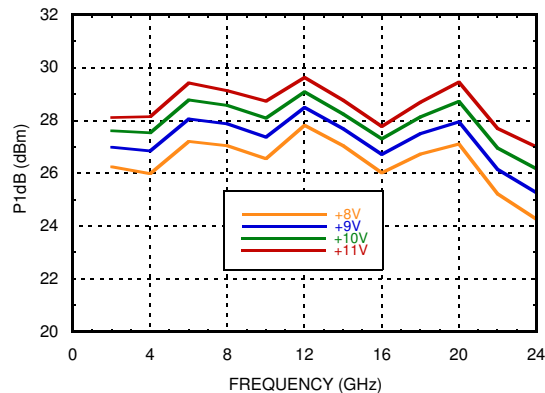


P1dB vs. Temperature

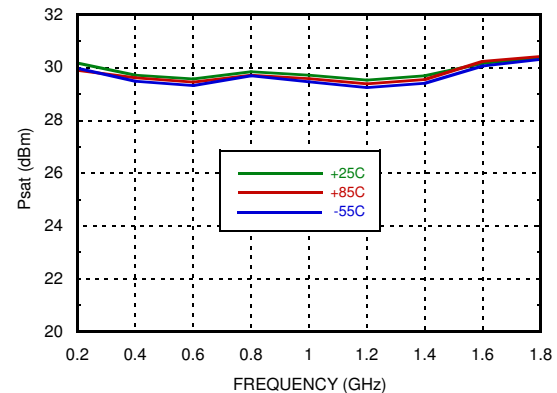


**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

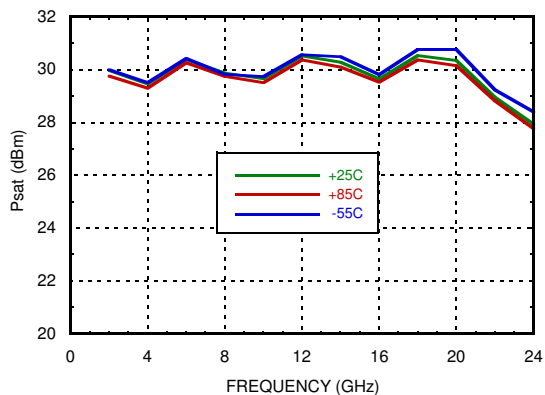
P1dB vs. Supply Voltage



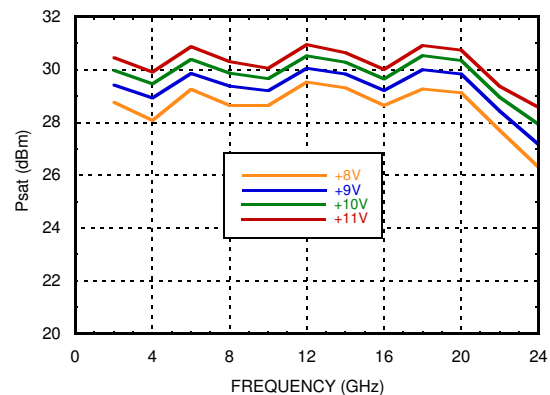
Low Frequency Psat vs. Temperature



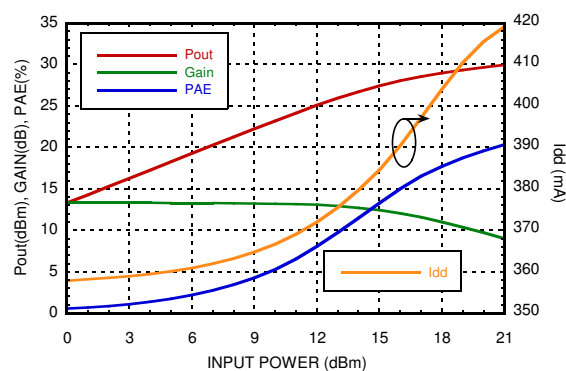
Psat vs. Temperature



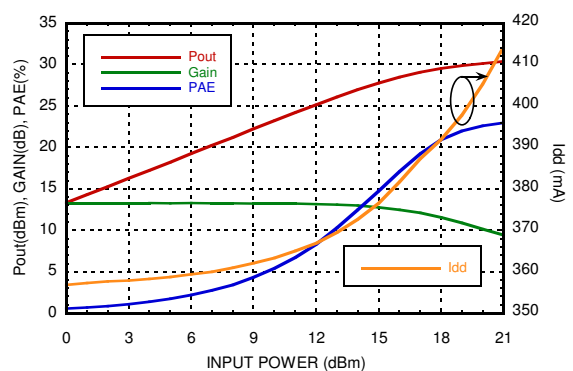
Psat vs. Supply Voltage



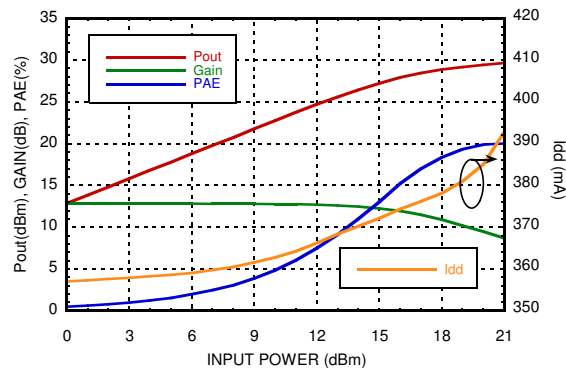
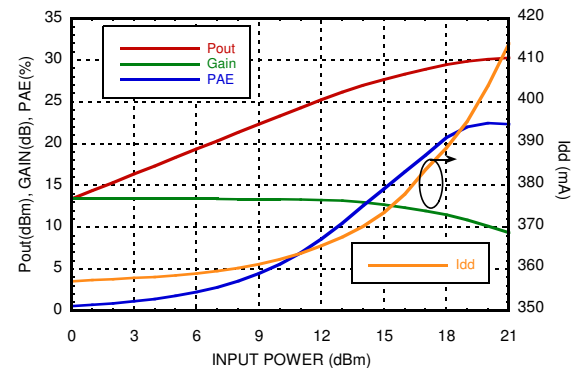
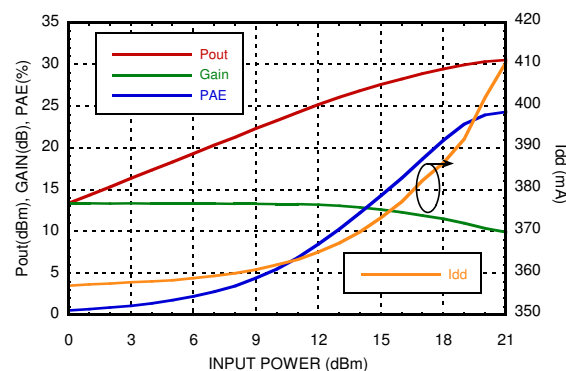
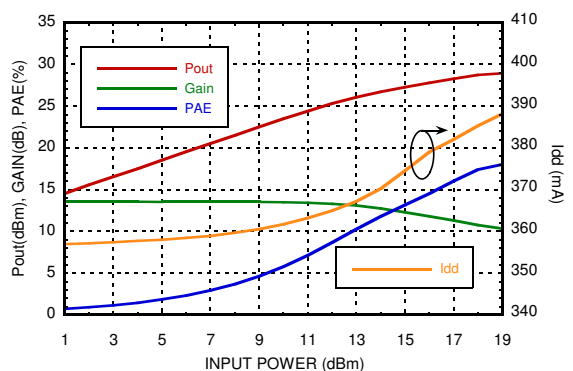
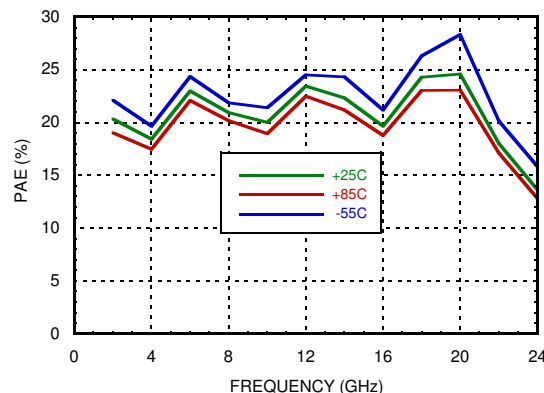
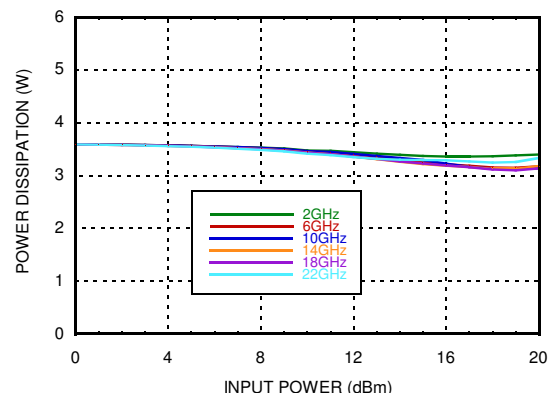
Power Compression @ 2 GHz



Power Compression @ 6 GHz

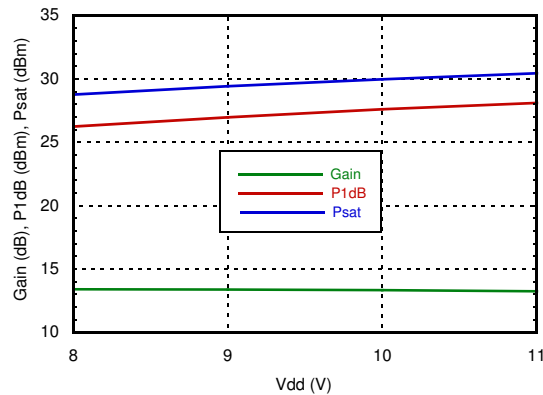


GaAs pHEMT MMIC POWER AMPLIFIER, 0.2 - 22 GHz

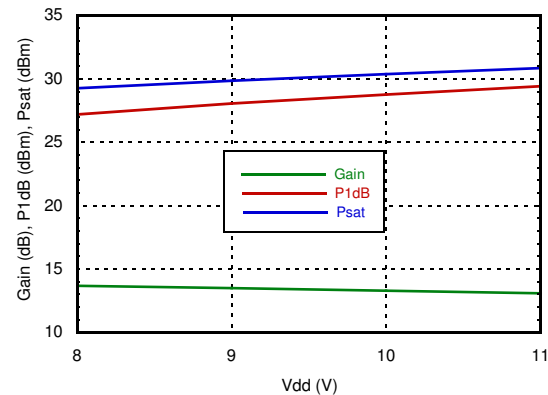
Power Compression @ 10 GHz

Power Compression @ 14 GHz

Power Compression @ 18 GHz

Power Compression @ 22 GHz

PAE @ Psat vs. Temperature

Power Dissipation @ +85 C


**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

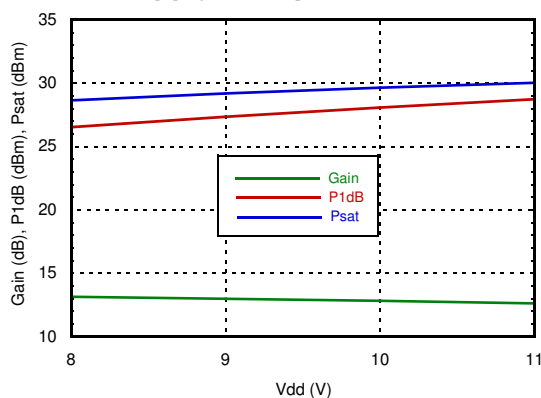
**Gain & Power vs.
Supply Voltage @ 2 GHz**



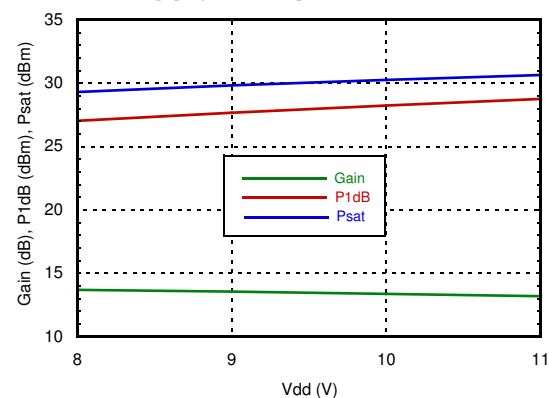
**Gain & Power vs.
Supply Voltage @ 6 GHz**



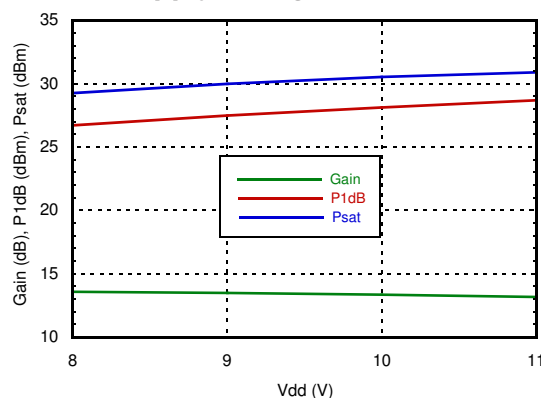
**Gain & Power vs.
Supply Voltage @ 10 GHz**



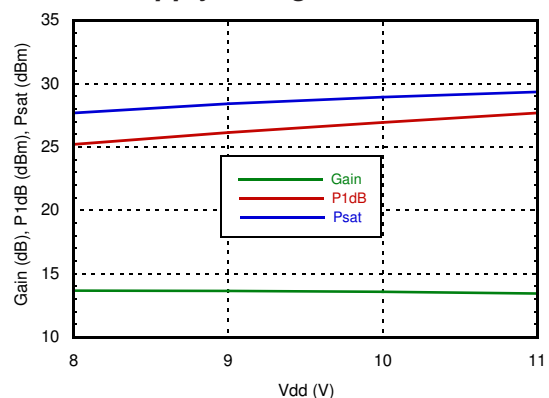
**Gain & Power vs.
Supply Voltage @ 14 GHz**



**Gain & Power vs.
Supply Voltage @ 18 GHz**

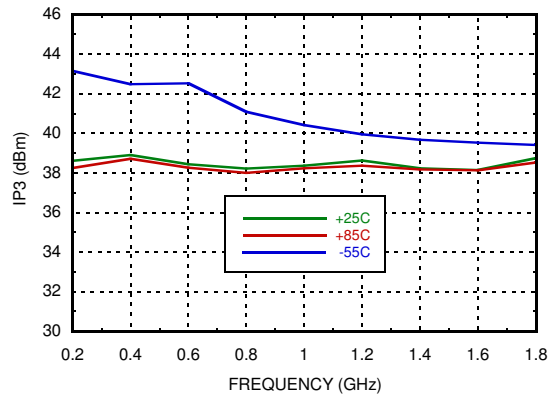


**Gain & Power vs.
Supply Voltage @ 22 GHz**

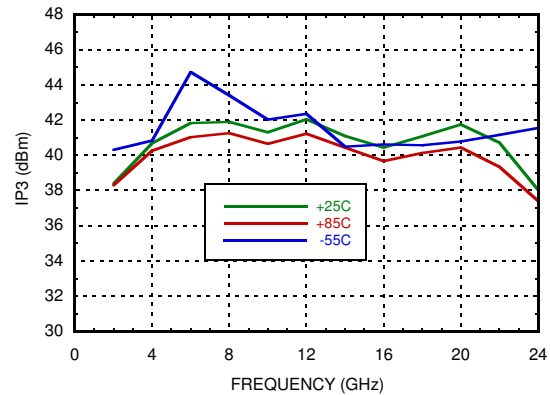


GaAs pHEMT MMIC POWER AMPLIFIER, 0.2 - 22 GHz

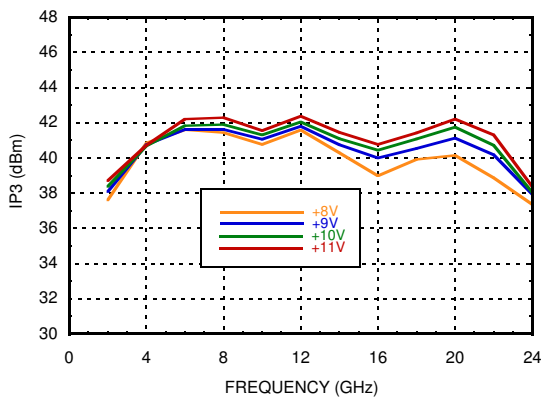
Low Frequency OIP3 vs. Temperature
@ Pout = +16 dBm / Tone



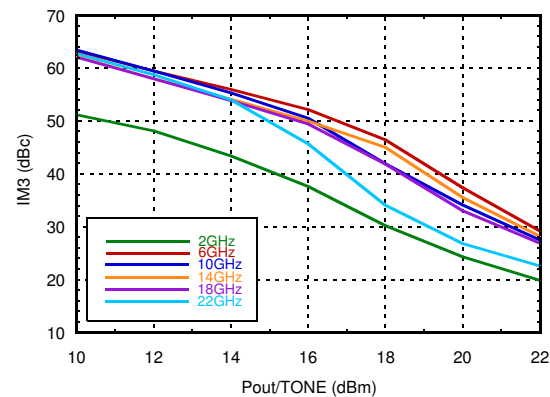
OIP3 vs. Temperature
@ Pout = +16 dBm / Tone



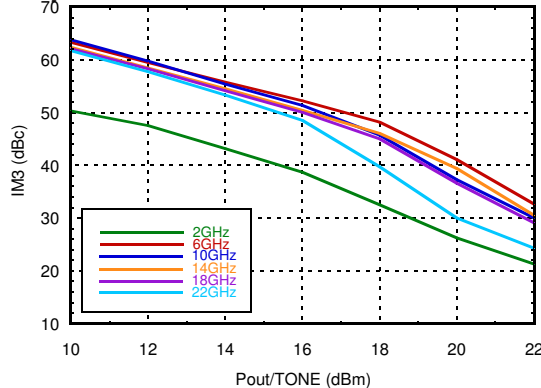
OIP3 vs. Supply Voltage
@ Pout = +16 dBm / Tone



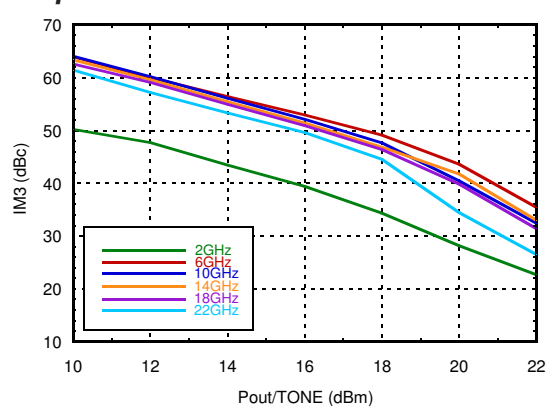
Output IM3 @ Vdd = +8V



Output IM3 @ Vdd = +9V

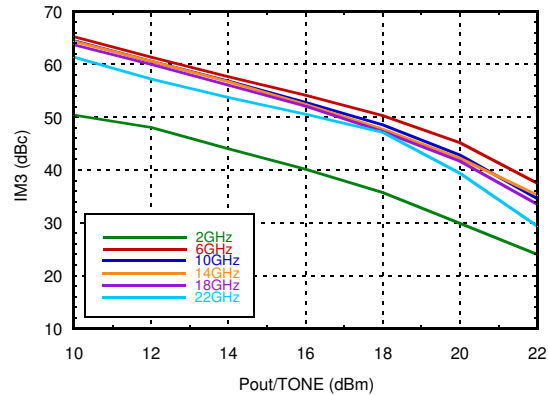


Output IM3 @ Vdd = +10V

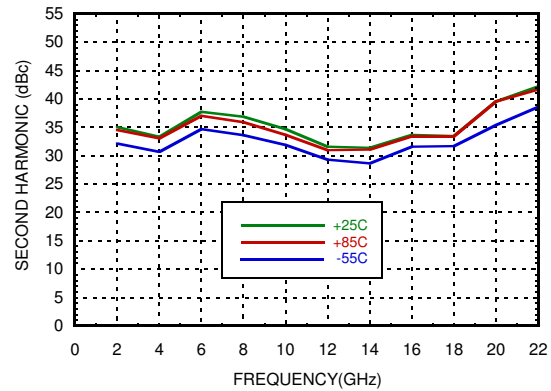


**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

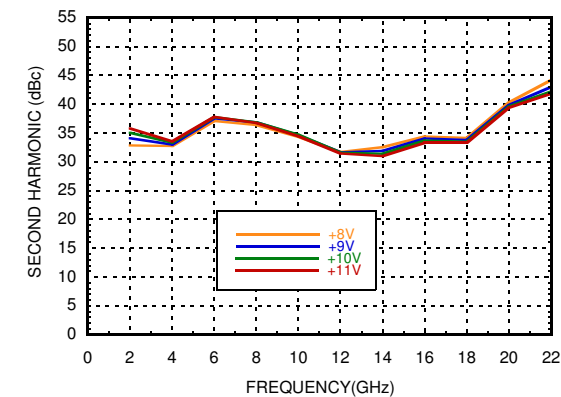
Output IM3 @ Vdd = +11V



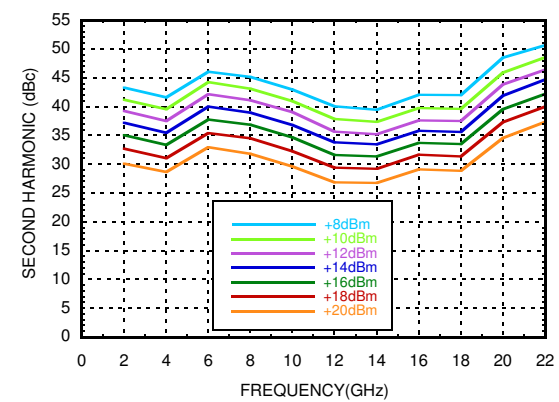
**Second Harmonics vs. Temperature
@ Pout = +16 dBm**



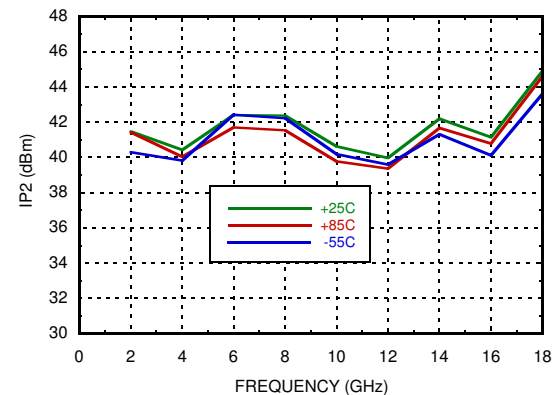
**Second Harmonics vs. Supply Voltage
@ Pout = +16 dBm**



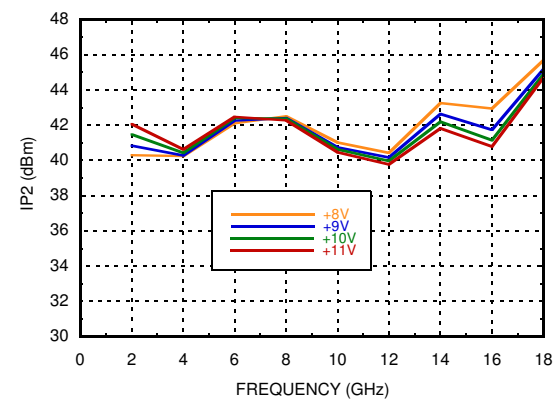
Second Harmonics vs. Pout



**OIP2 vs. Temperature
@ Pout = +16 dBm / Tone**

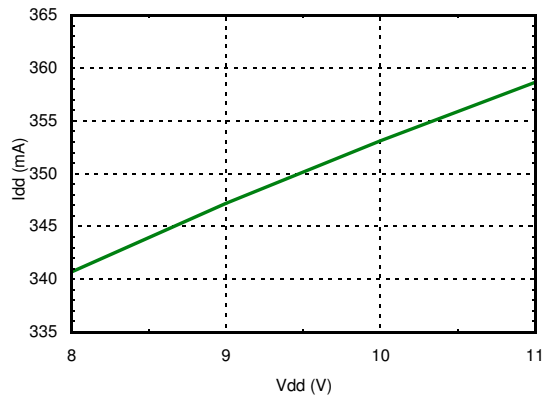


**OIP2 vs. Supply Voltage
@ Pout = +16 dBm / Tone**



**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

Supply Current vs. Supply Voltage



Absolute Maximum Ratings

Drain Bias Voltage (Vdd)	+12 Vdc
RF Input Power (RFIN)(Vdd = +10V)	+25 dBm
Output Load VSWR	7:1
Continuous P _{diss} (T = 85 °C) (derate 62 mW/°C above 85 °C)	5.6 W
Storage Temperature	-65 to 150°C
Operating Temperature	-55 to 85 °C
ESD Sensitivity (HBM)	Class1A, Passed 250V

Reliability Information

Channel Temperature to Maintain 1 Million Hour MTTF	175 °C
Thermal Resistance (channel to die bottom)	16.2°C/W

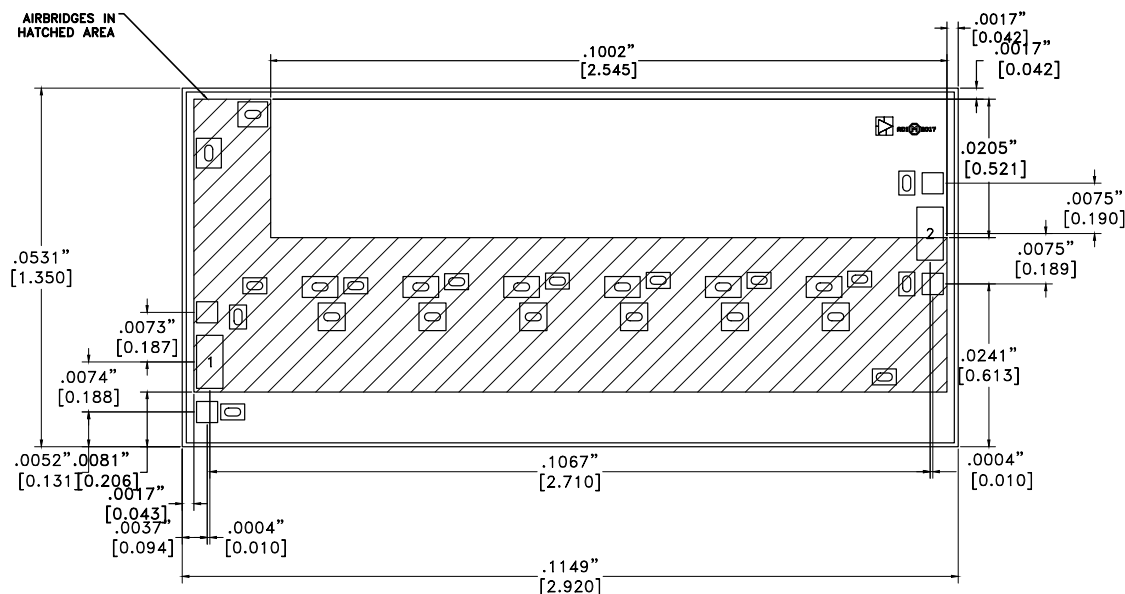
Stresses at or above those listed in the Absolute Maximum Ratings may cause permanent damage to the product. This is a stress rating only, functional operation of the product at these or any other conditions above those indicated in the operational section of this specification is not implied. Operation beyond the maximum operating condition for extended periods may affect product reliability.



**ELECTROSTATIC SENSITIVE DEVICE
OBSERVE HANDLING PRECAUTIONS**

GaAs pHEMT MMIC POWER AMPLIFIER, 0.2 - 22 GHz

Outline Drawing



This die utilizes fragile air bridges. Any pick-up tools used must not contact the die in the cross hatched area.

Die Packaging Information ^[1]

Standard	Alternate
GP-2 (Gel Pack)	[2]

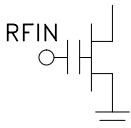
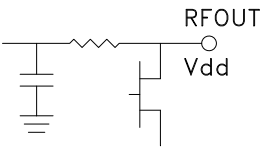

[1] Refer to the "Packaging Information" section for die packaging dimensions.

[2] For alternate packaging information contact Analog Devices, Inc..

NOTES:

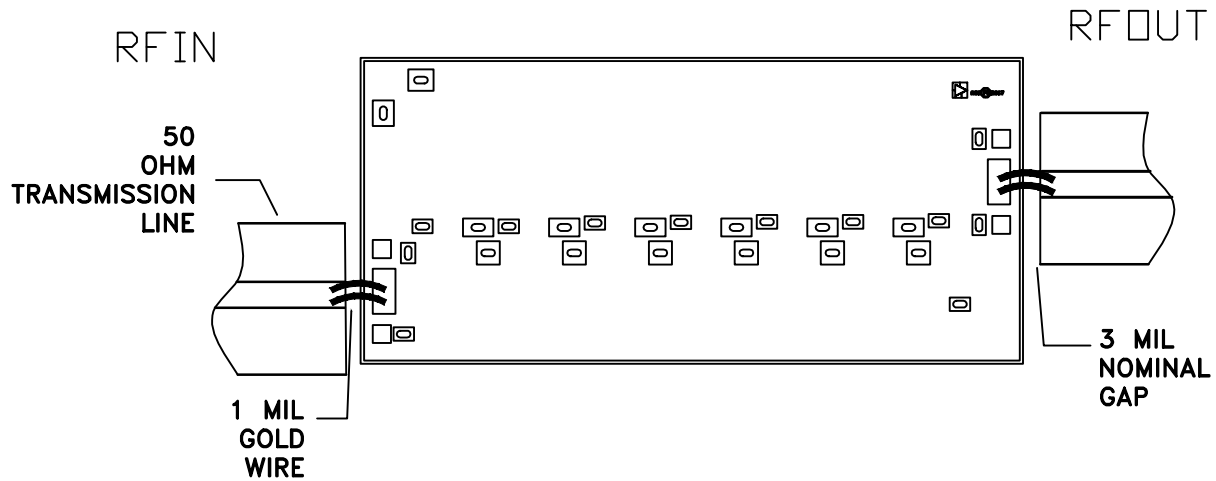
1. ALL DIMENSIONS IN INCHES [MILLIMETERS]
2. DIE THICKNESS IS 0.004 (0.100)
3. TYPICAL BOND PAD IS 0.004 (0.100) SQUARE
4. BOND PAD METALLIZATION: GOLD
5. BACKSIDE METALLIZATION: GOLD
6. BACKSIDE METAL IS GROUND
7. NO CONNECTION REQUIRED FOR UNLABELED BOND PADS
8. OVERALL DIE SIZE IS ± 0.002

Pad Descriptions

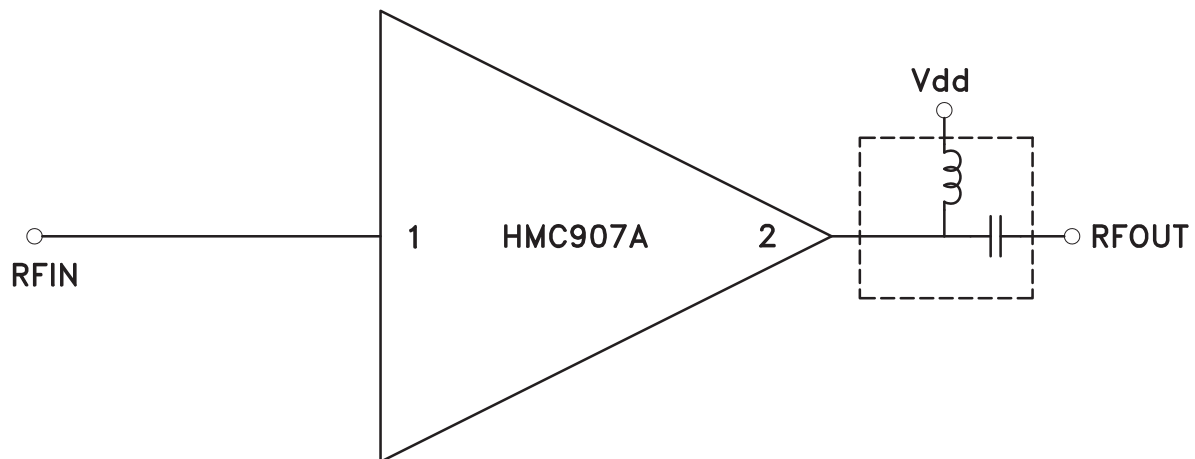
Pad Number	Function	Description	Interface Schematic
1	RFIN	This pad is DC coupled and matched to 50 Ohms.	
2	RFOUT & Vdd	RF output for amplifier. Connect DC bias (Vdd) network to provide drain current (Idd). See application circuit herein.	
Die Bottom	GND	Die bottom must be connected to RF/DC ground.	

**GaAs pHEMT MMIC
POWER AMPLIFIER, 0.2 - 22 GHz**

Assembly Diagram



Application Circuit



NOTE 1: Drain Bias (Vdd) must be applied through a broadband bias tee with low series resistance and capable of providing 500mA

For price, delivery, and to place orders: Analog Devices, Inc., One Technology Way, P.O. Box 9106, Norwood, MA 02062-9106
Phone: 781-329-4700 • Order online at www.analog.com
Application Support: Phone: 1-800-ANALOG-D

GaAs pHEMT MMIC POWER AMPLIFIER, 0.2 - 22 GHz

Mounting & Bonding Techniques for Millimeterwave GaAs MMICs

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be placed as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076mm to 0.152 mm (3 to 6 mils).

Handling Precautions

Follow these precautions to avoid permanent damage.

Storage: All bare die are placed in either Waffle or Gel based ESD protective containers, and then sealed in an ESD protective bag for shipment. Once the sealed ESD protective bag has been opened, all die should be stored in a dry nitrogen environment.

Cleanliness: Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity: Follow ESD precautions to protect against ESD strikes.

Transients: Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pick-up.

General Handling: Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip may have fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

Mounting

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

Eutectic Die Attach: A 80/20 gold tin preform is recommended with a work surface temperature of 255 °C and a tool temperature of 265 °C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 °C. DO NOT expose the chip to a temperature greater than 320 °C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach: Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

Wire Bonding

RF bonds made with two 1 mil wires are recommended. These bonds should be thermosonically bonded with a force of 40-60 grams. DC bonds of 0.001" (0.025 mm) diameter, thermosonically bonded, are recommended. Ball bonds should be made with a force of 40-50 grams and wedge bonds at 18-22 grams. All bonds should be made with a nominal stage temperature of 150 °C. A minimum amount of ultrasonic energy should be applied to achieve reliable bonds. All bonds should be as short as possible, less than 12 mils (0.31 mm).

